Wrap Up

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Topics for Next TWG

• Outgassing? Keep in Optics TWG, but include “pass down”
• Regional updates? Short presentations are good.
• Exposure tool dose calibrations and comparisons? Report Ezero from Berkeley calibration line, MET-2D at next meeting. Also calibrate MET to Ezero and then collect Esize. Do experiment at thinner resist. (Naulleau)
• Share resist screening data? No comments, data shown at conference.
• 22 nm resists? Invited talk by university or research, not covered at conference?
• 16nm resists?
• LER/LWR of devices or etched features (EUV)?
• Aspect ratio, thin film effects?
Plans for Next TWG Meetings

- Teleconference mid-July
  - Sapporo, Japan
  - Larger room, please